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APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/712,575	11/13/2003		Vijav Narayanan	YOR920030438US1	8789
24299	7590	11/15/2004		EXAM	INER
George Sai			HU, SHO	HU, SHOUXIANG	
Greenwich, RI 02818				ART UNIT	PAPER NUMBER
				2811	
			DATE MAILED: 11/15/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/712,575	NARAYANAN ET AL.				
Office Action Summary	Examiner	Art Unit				
	Shouxiang Hu	2811				
The MAILING DATE of this communication a Period for Reply	ppears on the cover sheet wi	th the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REF THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a r - If NO period for reply is specified above, the maximum statutory perion - Failure to reply within the set or extended period for reply will, by state than three months after the material patent term adjustment. See 37 CFR 1.704(b).	1.136(a). In no event, however, may a re eply within the statutory minimum of thirt of will apply and will expire SIX (6) MON ute, cause the application to become AB	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).				
Status						
2a) ☐ This action is FINAL . 2b) ☑ TI 3) ☐ Since this application is in condition for allow	<u>1</u>					
Disposition of Claims						
4) ⊠ Claim(s) <u>1-35</u> is/are pending in the application 4a) Of the above claim(s) <u>1-7 and 22-32</u> is/are 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) <u>8-21 and 33-35</u> is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and	re withdrawn from considera	tion.				
Application Papers	•					
9) The specification is objected to by the Exami 10) The drawing(s) filed on 13 November 2003 is Applicant may not request that any objection to the Replacement drawing sheet(s) including the correction. The oath or declaration is objected to by the	s/are: a) accepted or b) ⊠ ne drawing(s) be held in abeyan ection is required if the drawing	nce. See 37 CFR 1.85(a). (s) is objected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for forei a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a life	ents have been received. ents have been received in A riority documents have been eau (PCT Rule 17.2(a)).	pplication No received in this National Stage				
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/6	Paper No(s	Summary (PTO-413) s)/Mail Date nformal Patent Application (PTO-152)				

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DETAILED ACTION

Election/Restrictions

1. Claims 1-7 and 22-32 withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on 20040826.

Drawings

2. The drawings are objected to because what shown in Fig. 3 appears to be in error. The legend for the vertical axis in Fig. 3 includes the term of "Si (or N)/Si+Ta+N"; but the content ratio of any individual element to the total elements in the whole compound should not be larger than 1. Corrected drawing sheets in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. Any amended replacement drawing sheet should include all of the figures appearing on the immediate prior version of the sheet, even if only one figure is being amended. The figure or figure number of an amended drawing should not be labeled as "amended." If a drawing figure is to be canceled, the appropriate figure must be removed from the replacement sheet, and where necessary, the remaining figures must be renumbered and appropriate changes made to the brief description of the several views of the drawings for consistency. Additional replacement sheets may be necessary to show the renumbering of the remaining figures. The replacement sheet(s) should be labeled "Replacement Sheet" in the page header (as per 37 CFR 1.84(c)) so as not to

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obstruct any portion of the drawing figures. If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

Claim Objections

3. Claims 8-21 and 33-35 are objected to because of the following informalities and/or defects:

In claims 8 and 33, the term of "0.9" for the ratio should be read as: --0.9:1--.

Claims 12 and 27 each recite the subject matter that the Si to Ta elemental ratio in the recited TaSiN is between about 0.35 and 0.5; but, according to the specification (see lines 5-9 on page 7), it should be the Si content ratio with respect to the recited TaSiN that is between about 0.35 and .5.

Appropriate correction is required.

Claim Rejections - 35 USC § 102

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

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5. Claims 8-11 and 15-19, as being best understood in view of the claim objections, are rejected under 35 U.S.C. 102(b) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Grant (6,423,619).

Grant discloses a semiconductor filed effect device (Fig. 6; also see col. 2, line 53 through col. 3, line14), having a gate dielectric (22; SiO2 or ZrO2; can be less than 2nm in thickness) and a gate (24), wherein the gate comprises a compound of either TaN or TaSiN, which has a ratio of N:Ta about 1:1, and the resistivity of the compound therein is naturally below about 20mΩcm as the one recited in the instant invention, since the compound in Grant has a substantially same N:Ta ratio and is formed through a substantially same method (CVD) as the ones in the instant invention.

Or, in the alternative, it would have been obvious over Grant as it is art recognized that low resistivity for the gate electrode material is always desirable for reducing the gate resistance.

Regarding claim 11, the TaN in Grant naturally has a crystalline material structure.

6. Claims 8-21, as being best understood in view of the claim objections, are rejected under 35 U.S.C. 102(e) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Ngai (6,518,106).

Ngai discloses a semiconductor filed effect device (Fig. 5; also see col. 2, line 34 through col. 3, line 9), having a gate dielectric (40; SiO2 or ZrO2; can be less than 2nm in thickness) and a gate (50), wherein the gate comprises a compound of either

instant invention.

Tantalum Nitride or TaSiN, which (at least in TaSiN) has a ratio of N:Ta about 1:1, and the resistivity of the compound therein is naturally below about 20mΩcm as the one recited in the instant invention, since the compound in Ngai has a substantially same N:Ta ratio and is formed through a substantially same method (CVD) as the ones in the

Or, in the alternative, it would have been obvious over Ngai as it is art recognized that low resistivity for the gate electrode material is always desirable for reducing the gate resistance.

Regarding claims 10 and 11, a Tantalum Nitride compound is commonly expressed as TaN in the art, which naturally covers a Ta:N ratio of about 1:1, and, when formed through CVD, naturally has crystalline structure.

Regarding claim 12, the Si content ratio in TaSiN in Ngai naturally covers a ratio substantially the same as the one in the instant invention as the TaSiN workfunction in Ngai can be adjusted in a wide range of from 4.4 eV to 4.8 eV.

Regarding claim 13, the TaSiN in Ngai is naturally amorphous.

Regarding claims 14, 20 and 21, the TaSiN gate electrode in Ngai is used in an NMOS transistor; and it naturally covers a workfunction and a threshold as recited in the instant invention, as the TaSiN workfunction in Ngai can be adjusted in a wide range of from 4.4 eV to 4.8 eV.

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Claim Rejections - 35 USC § 103

7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8. Claims 33-35 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ngai.

The disclosure of Ngai is discussed as applied to claims 8-21 above.

Although Ngai does not expressly disclose that the field effect transistor can be used in a processor, it is noted that one of ordinary skill in the art would readily recognize that field effect transistors are widely and commonly used in devices such as digital processors and processors having analog circuits for achieving high performance and low power consumption in these devices.

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to incorporate the field effect transistors of Ngai into devices of digital processor and/or processors having analog circuits therein, electronic device with high performance and low power consumption would be obtained.

Conclusion

9. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. References C-F are cited as being related to a field effect transistor structure.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shouxiang Hu whose telephone number is 571-272-1654. The examiner can normally be reached on Monday through Thursday, 7:30 AM to 6:00 PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on 571-272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SH

November 9, 2004 Acoustics

SHOUXIANG HU PRIMARY EXAMINER